## First-principle study of the of oxygen behaviour in γ-TiAl

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## Abstract

New TiAl-based alloys, as for instance the  $\gamma$ -TiAl intermetallic, are adopted for the last generation turbomachines in aerospace industry and their use is likely to increase in the future<sup>1</sup>. In this evolution, the environmental conditions will move to higher temperature and pressure conditions. The oxidation behaviour is therefore essential for such applications and it has been studied in the past<sup>2</sup>. However, fundamental data, as the diffusion coefficients of oxygen in these materials, are missing. The aim of this work is to derive these quantities from *ab initio* methods.

γ-TiAl crystallizes in the *P4/mmm* space group and it can be seen as built by two structural units, constituted by octahedra, respectively made of 4Al+2Ti and 4Ti+2Al atoms. These sites are herein labelled as  $[Ti_2Al_4]$  and  $[Ti_4Al_2]$ . The accommodation of O atoms in the centre of these octahedra has been investigated by *DFT* calculations performed with the *VASP*<sup>3</sup> code, using the projector augmented wave pseudopotential and the GGA approximation. Vibrational properties and interatomic forces constants were obtained by the finite displacement method, using the *phonopy*<sup>4</sup> code. The results indicate that oxygen is not stable in the octahedral sites and that, when the structure is fully relaxed, it moves toward two other interstitial sites (Figure 1): the first, named α, corresponds to the Al-Al corners in  $[Ti_2Al_4]$ ; the second, named β, is obtained by a shift along the *z* direction, toward the top or the bottom of the  $[Ti_4Al_2]$  octahedral centre. The latter is the site with lowest energy.



Figure 1. α and β interstitial sites occupied by oxygen (yellow) in γ-TiAl (Al in blue, Ti in red).

The atomic mechanism behind the diffusion of oxygen atoms in  $\gamma$ -TiAl were then studied using the Nudged Elastic Band (NEB) method as implemented in VASP<sup>3</sup>. This allowed identifying the minimum energy paths (MEPs) for the jumping of oxygen through the interstitial  $\alpha$  and  $\beta$  sites and the relative barrier energies. Our results indicate that the diffusion of oxygen in  $\gamma$ -TiAl is a complex process, which includes several steps. For each of this, the jumping rate *v* was computed according to the transition state theory<sup>5</sup> as:

$$v = v^* e^{-\Delta E/kT}$$

where  $\Delta E$  is the barrier energy, *T* is the temperature, *k* is the Boltzmann constant and  $v^*$  is referred as an *attempt frequency*, which can be obtained from the phonon bands computed at the saddle point and the starting point of the MEP. Finally, the analytical multistate diffusion method<sup>6</sup> was applied to obtain the diffusion coefficients in the different crystallographic directions and the results are shown in Figure 2.





The results indicate generally low diffusion coefficients and a clear anisotropy between the basal plane ( $D_x = D_y$ ) and the *z* direction, with diffusion being faster in the former.

## References

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